



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

D. KOMADA

Group Art Unit: 1765

Serial No.: 10/040,378

Examiner: Lan Vinh

Filed: January 9, 2002

Atty. Dck. No. 107317-00040

For: MANUFACTURE METHOD FOR SEMICONDUCTOR DEVICE HAVING  
SILICON-CONTAINING INSULATING FILM

**RESPONSE**

Director for the U.S. PTO  
P.O. Box 1450  
Alexandria, VA 22313-1450

Date: March 15, 2004

Sir:

In reply to the outstanding Office Action dated November 20, 2003, the period for response having been extended one month from February 20, 2004 to March 20, 2004, with the filing of the attached Petition for Extension of Time, reconsideration of the above-identified patent application is requested in view of the remarks on the following pages: